Electron Bolus Creation

An electron bolus is an option device for each electron treatment beam. A user is able to add an electron bolus to their beams to aid in proper distribution of dose.

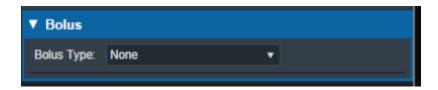


Fig. 1: Beams Block

There are four options for boluses in the decimal eRT app as defined below:

Optimized Thickness Bolus

The first option a user has for creating an bolus for the selected beam is an optimized thickness bolus. The user can select the "Generate Bolus" option and have the application automatically create an optimized bolus that will best attempt to put the beam's specified isodose level to the distal edge of the target. Once the application has finished calculating you will notice the bolus gets added to the beam.

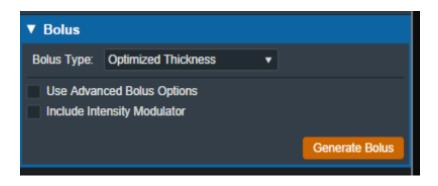


Fig. 2: Beams Block

If the need arises a user can also access advanced options for modifying an existing bolus or create a new one from scratch.

In the advanced options you can add the following operators to augment your bolus:

The following construction operators are only available when first creating a new bolus.

• Automated Marching

- This operator constructs the proximal bolus surface using a series of incremental steps. Each step consists of a small thickness reduction at the optimally selected locations, followed by a hot spot damping step, in which the slopes of the bolus surface are reduced in areas where high dose values are found.
- Geometric Sequence

 This operator constructs the proximal bolus surface by first computing the physical depth to the distal PTV surface along each ray line of the bolus point grid. The initial bolus thickness required at each point is then computed based on the specified prescription value (for ray lines not intersecting the PTV, an extension is performed using the heights of the points that do intersect, which helps ensure the PTV edges are adequately covered). The resulting surface is then smoothed.

• Single shift Sequence

- This operator performs the Geometric Sequence operations and then performs a single Isodose Shift operator and Smooth operator
- Double Shift Sequence
 - $\circ\,$ This operator performs the Geometric Sequence operations and then performs two Single Shift operations
- Create
 - This operator constructs the proximal bolus surface by first computing the physical depth to the distal PTV surface along each ray line of the bolus point grid. The initial bolus thickness required at each point is then computed based on the specified prescription value (for ray lines not intersecting the PTV, an extension is performed using the heights of the points that do intersect, which helps ensure the PTV edges are adequately covered).



that best jives with end uers.

The following operators are only available after one of the above bolus construction operators have been performed:

Smooth

- This operator performs a Gaussian type smoothing on the current bolus proximal surface, which uses a distance weighted average of the neighboring point heights to shift each field point. Note that this operator can only be used after at least one construction operation has been performed.
- Isodose shift
 - This operator updates a bolus proximal surface by using the dose field results from the current design to adjust the bolus heights by the deviation of the prescribed dose isocontour and the distal PTV surface.
- Truncate
 - This operator updates a bolus proximal surface by reducing the height of the bolus in the region outside the Block Outer Border. The height is reduced to be slightly above (2mm-6mm depending on size) the highest point in the modulated region. It should be mentioned that truncating a bolus may limit the ability to shift points upward (increase in thickness) when performing manual isodose shift operators after the truncate.
- Specified Shift
 - This operator updates a bolus proximal surface by shifting all points (even the region beyond the Block Outer Border) by the specified distance.
- Intensity Modulation
 - This operator manually adds an Intensity Modulator operation to bolus design. Including this
 operator results in the beam including the Intensity Modulator device. If multiple Intensity
 Modulation operators are added in the operator list, then that results in multiple iterations of

the modulation calculation.

For each operator once it is selected from the list the UI updates to show the options for that operation. Once the options have been finalized the user can add the operator and re-compute for and existing bolus or generate a new one with the selected operator.

Here we have an example of adding the automated marching to a new bolus:

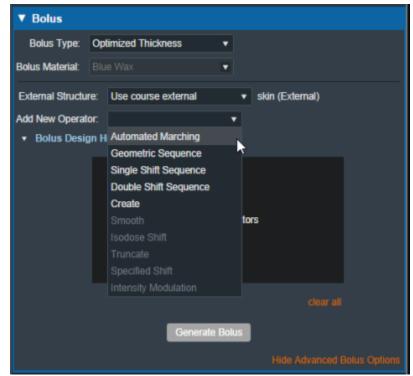


Fig. 3: New bolus operator options

Bolus Type:	Optimized Thickness			•		
Bolus Material:				•		
External Strue	cture:	Use co	urse exter	nal	٠	skin (External)
Add New Ope	rator:	Automa	ated March	ning	•	
Bolus Geometry Options						
Block Outer Bo	order:	1	cm			
Target Inner Bo	order:	0.2	cm			
Depth Beyond Ta	arget	0.5	cm			
Minimum Thick	ness:	0.2	cm			
Distal PTV Smool	thing:	0	cm			
Include Inten	sity Mo	dulator				
 Bolus Desig 	n Histo	лy				
			Gene	rate Bolus		▶
						Hide Advanced Bolus Options

Fig. 4: Adding an automated marching operator

The advanced optimized thickness bolus design parameters allow the user to fine tune the bolus design for specific operators. These options include:

• Block Outer Border:

 $\circ\,$ The distance to extend the bolus surface beyond the block/collimator perpendicular to the CAX.

• Target Inner Border:

 Specifies the distance to offset the target projection inward when defining the region over which initial construction and smoothing operators act. This is used to reduce the effects that the rapid PTV height changes near the target edges can have on the construction and smoothing operators.

• Depth Beyond Target:

- The beams-eye-view distance past the selected target (along the CAX direction) at which the patient-side surface will be truncated.
- Minimum Thickness:
 - The minimum allowable thickness of the bolus as measured along a beam aligned rayline
- Distal PTV Smoothing:
 - The smoothing ball radius used to smooth the target structure. A larger radius will result in more smoothing but will also cause a greater deviation of the target from the orignal structure. Note that setting this value to 0 mm will result in no smoothing for the target structure
- Smoothing Factor: (Smoothing operator only)
 - The exponential smoothing weight coefficient (smaller value increases smoothing)
- Smoothing Size: (Smoothing operator only)
 - The smoothing distance factor (larger values spread the smoothing range further)
- Additional Thickness: (Specified Shift operator only)
 - The thickness to add to the bolus proximal surface (use a negative value to reduce height)

Additionally by selecting the "Bolus Design History" you can see a list of every step in the bolus design, each step is removable individually as well as having the option to clear all steps and start from scratch.

▼ Bolu	s Design History	
	0: create	
	1: smooth	
	2: isodose_shift	×
		clear all

Fig. 5: Bolus design history list

Uniform Thickness Bolus

When adding a uniform thickness bolus the user must add the UTB to all the beams in the plan. Once the plan level bolus has been selected the dose will be recalculated to reflect the new bolus.

▼ Bolus		
Bolus Type:	Uniform Thickness	•
Plan Level Bolu	us: ensity Modulator	۲

Fig. 8: Beams Block

Bolus as a Structure

The user also has the option to instead include a bolus as a separate structure in the structure list. Once the option is chosen the user will be able to find the bolus structure from the drop down structure list and the app will set it as the bolus for this beam.

	000 01 00 01 0 00 00 00 00 00 00 00 00 0	
Structure:	Electron Bolus 🔹	
Include Inte	PTV	
	PTV 6840	
	Rt Parotid	
	Cord	
	Cord+5	
	Ant avoid	
	Post avoid	
	Rt Eye	
	Lt Eye	
	External	
	BOLUS 1CM	
	ptv p5	
	ptv p20	
	nose	
	90 % (Trial_1)_1	
	Electron Bolus	
	*	

Fig. 9: selecting from the structure list

▼ Bolus			
Bolus Type:	Use Structure As Bolus	۲	
Structure:	Electron Bolus	•	
Include Int	ensity Modulator		

Fig. 10: selecting a Bolus as a structure

Once the structure is selected the bolus will be added to this beam and dose re-calculated as expected.

Note: The bolus is displayed in the BEV for this beam even though the "Electron Bolus" structure is hidden through the right hand side controls. This shows that the displayed bolus is added as a bolus on this beam and not appearing as a structure.

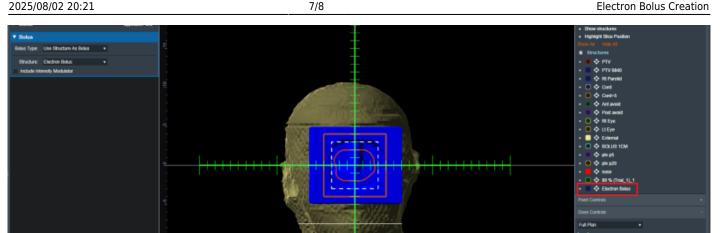


Fig. 11: Bolus in BEV

If you with to import a bolus that is not currently in your structure list please refer to the DICOM Patient Import section of the user guide for how to re-import a structure set.

Intensity Modulator Device

Additionally if any type of bolus is added to a beam the user is able to also include an intensity Modulator by selecting the option below any bolus type. The application with calculate the device and display it in the beams UI.

NOTE: In order to add an IMET device the selected beam MUST have a valid bolus.

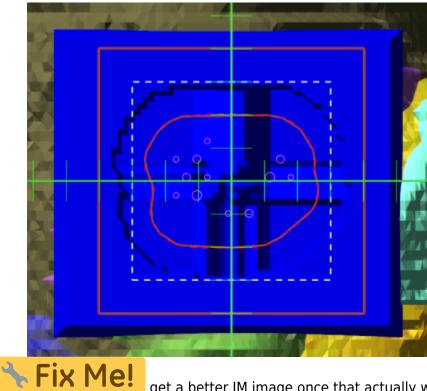


Fig. 12: BEV IMET

get a better IM image once that actually works...

And as with a bolus the device can be hidden and un-hidden from the display using the beam controls on

the right hand size.

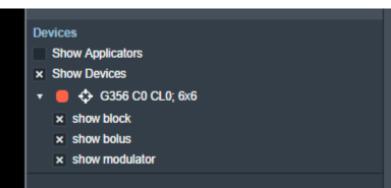


Fig. 14: RHS options to hide/show devices

From: http://apps.dotdecimal.com/ - decimal App Documentation

Permanent link: http://apps.dotdecimal.com/doku.php?id=electronrt:userguide:tutorials:electron_bolus&rev=1600694910

Last update: 2021/07/29 18:24

